

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of

KOBAYASHI, S.

Atty. Ref.: 900-471

Serial No. To be assigned

Group:

Filed: August 4, 2003

Examiner:

For: MASK PATTERN AND METHOD FOR FORMING RESIST  
PATTERN USING MASK PATTERN THEREOF

\* \* \* \* \*

August 4, 2003

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**INFORMATION DISCLOSURE STATEMENT**

As suggested by 37 C.F.R. 1.97, the undersigned attorney brings to the attention of the Patent and Trademark Office the references listed on the attached form PTO-1449, a copy of each of which is enclosed. This is not to be construed as a representation that a search has been made or that no better prior art exists, or that a reference is relevant merely because cited.

The Examiner is requested to initial the attached form PTO-1449 and to return a copy of the initialed document to the undersigned as an indication that the attached references have been considered and made of record.

Respectfully submitted,

**NIXON & VANDERHYE P.C.**

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<b>INFORMATION DISCLOSURE CITATION</b>	<b>ATTY. DOCKET NO.</b>	<b>SERIAL NO.</b>
	<u>900-471</u>	<u>To be assigned</u>
	<b>APPLICANT</b>	
	<u>KOBAYASHI, S.</u>	
(Use several sheets if necessary)	<b>FILING DATE</b>	<b>GROUP</b>
	<u>August 4, 2003</u>	

## **U.S. PATENT DOCUMENTS**

## **FOREIGN PATENT DOCUMENTS**

**OTHER DOCUMENTS (including Author, Title, Date, Pertinent pages, etc.)**

\*Examiner

### Date Considered

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to application.